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journal or publication title	Thin solid films
volume	515
number	22
page range	8216-8218
year	2007-08
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URL	<a href="http://hdl.handle.net/2241/97878">http://hdl.handle.net/2241/97878</a>

doi: 10.1016/j.tsf.2007.02.047

# Effects of Sr addition on crystallinity and optical absorption edges in ternary semiconducting silicide $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$

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Polycrystalline  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  films with the Sr composition  $x$  varying from 0 to 0.77 were grown on transparent fused silica substrates by molecular beam epitaxy, and the effects of Sr addition on the indirect optical absorption edge  $E_{\text{edge}}$  were investigated. It was found that the  $E_{\text{edge}}$  value increases almost linearly with increasing  $x$  and reached approximately 1.40 eV when  $x$  was 0.52. When  $x > 0.6$ , the  $E_{\text{edge}}$  value almost saturates, and the formation of homogeneous  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  films became difficult. Phase separation was observed for  $x = 0.77$ .

**Keyword:**  $\text{BaSi}_2$ , optical absorption, solar cell, molecular beam epitaxy

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## 1. Introduction

Most solar cells currently produced are Si based. However, the band gap,  $E_g$ , of Si is as small as 1.1 eV at room temperature (RT). This value is approximately 0.3 eV smaller than the ideal band gap ( $\sim 1.4$  eV) that matches the solar spectrum [1]. This small  $E_g$  value for Si results in low photoelectric conversion efficiency of Si solar cells. In addition, approximately 200- $\mu\text{m}$ -thick Si is required to form crystalline Si solar cells due to its small optical absorption coefficient  $\alpha$ . Thus, new Si-based materials for high-efficiency thin-film solar cells are needed. Semiconducting orthorhombic barium disilicide ( $\text{BaSi}_2$ ) is thought to be a good candidate for such a material.

The  $E_g$  value of  $\text{BaSi}_2$  has been previously ascertained from the temperature dependence of resistivity and diffuse reflectance spectra in bulk  $\text{BaSi}_2$  [2,3] and from scanning tunneling spectroscopy results of a few-monolayer-thick  $\text{BaSi}_2$  films on Si [4], to be approximately 1.1–1.3 eV at RT. The optical absorption spectra of polycrystalline  $\text{BaSi}_2$  films on transparent fused silica substrates show that its indirect absorption edge  $E_{\text{edge}}$  is approximately 1.3 eV. In addition,  $\alpha$  reaches  $10^5 \text{ cm}^{-1}$  at 1.5 eV [5], which is approximately two orders of magnitude higher than the value for Si. This large  $\alpha$  is thought to come from the contribution of the Ba  $5d$  state to both the conduction and valence bands in  $\text{BaSi}_2$  [6]. From the viewpoint of application to solar cells, it is desirable to increase the band gap to 1.4 eV by applying band-gap engineering to  $\text{BaSi}_2$ , that is, by replacing some of the Ba atoms with

isoelectric alkaline-earth metal atoms. The formation of  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  bulk itself has already been reported [7]. However, there were no descriptions of its optical properties. We have realized epitaxial growth of  $\text{BaSi}_2$  and  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  on Si(111) by molecular beam epitaxy (MBE) [8-11]. X-ray diffraction (XRD) measurements revealed that the  $a$ -axis lattice constant of  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  decreases linearly with increasing Sr composition  $x$  [10]. Very recently, we reported that the indirect optical absorption edge  $E_{\text{edge}}$  in  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  increases almost linearly with increasing Sr composition  $x$  when  $0 \leq x \leq 0.5$  [12].

The purpose of this study is to investigate the details of the effect of Sr addition on crystallinity and optical absorption properties of  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$ . For this purpose, we prepared  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  films with different  $x$  values on transparent fused silica substrates covered with pre-deposited polycrystalline Si layers. The phase separation and saturation of  $E_{\text{edge}}$  in  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  with Sr compositions higher than 0.6 are described.

## 2. Experimental

An ion-pumped MBE system equipped with standard Knudsen cells for Ba and Sr, and an electron-beam evaporation source for Si was used. Transparent fused silica substrates covered with 100-nm-thick polycrystalline Si layers were used, so that the contribution of the substrate to the measured optical absorption spectra would be small [5]. The pre-deposited Si layers prevent diffusion of O atoms from the substrate into the grown layers. After hydrogen

termination of the Si surfaces that were etched by a HF solution, the wafers were thermally cleaned in UHV. Polycrystalline  $Ba_{1-x}Sr_xSi_2$  films with various  $x$  values ranging from 0 to 0.77 were then grown using MBE. The thickness of the grown layers was approximately 200 nm. Details of the growth procedure have been described in our previous papers [5,12]. The crystalline quality of  $Ba_{1-x}Sr_xSi_2$  was characterized by XRD measurements. The composition of the grown layers was evaluated by Rutherford backscattering spectroscopy (RBS) measurements using  $^4He^+$  ions accelerated at 2.3 MeV. The optical absorption spectra of  $Ba_{1-x}Sr_xSi_2$  were measured at RT using a double-beam spectrophotometer (JASCO V570) in a transmission configuration.

### **3. Results and discussion**

RBS and XRD measurements were performed in order to confirm the formation of  $Ba_{1-x}Sr_xSi_2$  films. The RBS random spectra obtained experimentally were reproduced by simulations, and the Sr composition was then derived. Figures 1(a) and 1(b) show the RBS depth profiles of Ba, Sr, Si and O atoms in  $Ba_{1-x}Sr_xSi_2$  for  $x=0.29$  and  $0.52$ . Ba and Sr were homogeneously distributed, and the Ba plus Sr ratio to Si was 0.5 in the grown layers. Similar results were obtained for  $Ba_{1-x}Sr_xSi_2$  when  $x$  was lower than 0.6. On the other hand, several samples were prepared wherein  $x$  was higher than 0.6, however, we have not yet succeeded in forming  $Ba_{1-x}Sr_xSi_2$  with homogeneous Ba and Sr distributions, as shown in Figs. 1(c) and

1(d). Values of  $x$  of 0.64 and 0.77 were obtained, assuming that the Sr atoms were homogeneously distributed in the grown layers.

The  $\theta$ - $2\theta$  XRD patterns of polycrystalline  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  for  $x=0, 0.29, 0.52, 0.64$  and  $0.77$  are shown in Figs. 2(a)–2(e), respectively. The origin of the broad diffraction peak seen at  $\sim 21^\circ$  in all the samples is the substrate, as seen from Fig. 2(f). All the diffraction peaks seen in the sample without Sr addition (Fig. 2(a)) correspond to  $\text{BaSi}_2$ , and they shifted clearly to a high-angle-region with increasing  $x$  as shown in Figs. 2(a)–2(d). The dotted lines are guides to the eye. This result indicates that the lattice spacing of the film decreased with increasing  $x$ . The atomic radius of Sr is smaller than that of Ba. Thus, when some Ba atoms in the  $\text{BaSi}_2$  lattice structure are replaced by Sr atoms, this kind of lattice contraction will take place. It was found from XRD peak positions that  $a$  and  $b$  lattice constants in  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  decreased linearly with increasing  $x$ . Detailed results will be reported elsewhere. Similar lattice contraction is observed in  $\text{Ca}_{1-x}\text{Ba}_x\text{F}_2$  [13], which is completely miscible and obeys Vegard's law across the entire composition range. In contrast, the diffraction peak of the (301) plane splits into two peaks in the sample with  $x=0.77$  as shown in Fig. 2(e). The peak position of the low-angle diffraction is the same as that of the  $\text{BaSi}_2(301)$  plane. Thus, the high-angle diffraction is thought to correspond to the (301) plane of  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$ . The peak position of the (301) plane of  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  does not change between  $x=0.64$  and  $0.77$ . Therefore, the additional Sr might segregate in the form of Sr-Si silicides.  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  is not stable for high Sr content

because SrSi<sub>2</sub> with a BaSi<sub>2</sub>-type structure does not exist at RT. Phase separation is therefore thought to take place for high Sr content.

Figure 3 shows  $(\alpha d h\nu)^{1/2}$  versus  $h\nu$  plots obtained for the 100-nm-thick BaSi<sub>2</sub>, 200-nm-thick Ba<sub>0.71</sub>Sr<sub>0.29</sub>Si<sub>2</sub> and Ba<sub>0.48</sub>Sr<sub>0.52</sub>Si<sub>2</sub>, and 100-nm-thick Ba<sub>0.36</sub>Sr<sub>0.64</sub>Si<sub>2</sub> at RT, where  $h\nu$  is the photon energy, and  $d$  the thickness of the grown layers. The  $(\alpha d h\nu)^{1/2}$  values of Ba<sub>1-x</sub>Sr<sub>x</sub>Si<sub>2</sub> (x=0.29, 0.52 and 0.64) are multiplied by some factors, so that the plots shift downwards or upwards to be distinguished in Fig. 3. This operation does not affect the optical absorption edges. The influence of the pre-deposited polycrystalline Si layer and the fused silica substrate was already subtracted by comparing the transmittance measured on the samples with and without the grown layers. The plots are fitted to straight lines, showing that BaSi<sub>2</sub> and Ba<sub>1-x</sub>Sr<sub>x</sub>Si<sub>2</sub> are indirect band gap semiconductors. The indirect absorption edge,  $E_{\text{edge}}$ , with phonon emission is thus obtained from the intersection of the straight line with the horizontal axis. The values of  $E_{\text{edge}}$  obtained for BaSi<sub>2</sub> and Ba<sub>1-x</sub>Sr<sub>x</sub>Si<sub>2</sub> (x=0.29, 0.52 and 0.64) were 1.30, 1.35, 1.40 and 1.40 eV, respectively, as shown in Fig. 3. Indirect absorption by phonon absorption is neglected, because the fitting was performed at a higher energy region than the indirect band gap. An alternative interpretation of this absorption edge is the presence of the Urbach tail. However, a plot of  $\alpha$  vs.  $h\nu$  did not yield an exponential dependence. Therefore, the absorption edge can be better interpreted as being due to indirect absorption rather than due to the Urbach tail absorption.



The  $E_{\text{edge}}$  values of the other samples were derived in the same way, and are summarized in Fig. 4 which shows  $E_{\text{edge}}$  as a function of  $x$  in  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  measured at RT. It was found that  $E_{\text{edge}}$  increases almost linearly with increasing  $x$  and reaches approximately 1.40 eV when  $x$  is 0.52. This suggests that the band gap of  $\text{BaSi}_2$  is increased by the addition of Sr. It was also found that  $E_{\text{edge}}$  slightly scatters, depending on its thickness (see the  $E_{\text{edge}}$  of  $\text{BaSi}_2$ ); however, the dispersion of  $E_{\text{edge}}$  was 30 meV at most. On the basis of the above results, we conclude that  $E_{\text{edge}}$  of  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  is increased by approximately 0.1 eV by increasing the Sr composition  $x$  up to 0.52. On the other hand, the  $E_{\text{edge}}$  value almost saturates for  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  when  $x$  is 0.64. Taking into account the fact that the formation of  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  with  $x > 0.6$  is difficult, as described above, it can be stated that the expansion of  $E_{\text{edge}}$  in  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  is limited up to approximately 1.4 eV.

#### 4. Conclusions

$\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  films with various Sr compositions were grown on transparent fused silica substrates by MBE, and the effects of Sr addition on the crystallinity and optical absorption properties were investigated.  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  films with homogeneous Ba and Sr distributions were obtained when  $x < 0.5$ . The  $E_{\text{edge}}$  value increased almost linearly with increasing  $x$  and reached approximately 1.40 eV when  $x$  was 0.52. On the other hand, for higher  $x$  values, the  $E_{\text{edge}}$  value saturated, and the formation of homogeneous  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  films itself was difficult

for samples in which  $x > 0.6$  since phase separation occurred.

### **Acknowledgements**

The authors would like to express their sincere thanks to Prof. K. Matsuishi of the University of Tsukuba for his help in the absorption measurements. This work was partially supported by the Ministry of Education, Culture, Sports, Science and Technology (MEXT) of Japan, PREST of JST, and by the TEPCO Research Foundation.

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Figure 1 RBS depth profiles of Si, Ba, Sr and O atoms for  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  grown on transparent fused silica substrates when x is (a) 0.29, (b) 0.52, (c) 0.64 and (d) 0.77.

Figure 2  $\theta$ -2 $\theta$  XRD patterns of  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  films grown on transparent fused silica substrates when x is (a) 0, (b) 0.29, (c) 0.52, (d) 0.64, and (e) 0.77; (f) is the XRD pattern of the substrate used. The dotted lines are guides to the eye.

Figure 3  $(\alpha d h \nu)^{1/2}$  versus  $h \nu$  plots for 100-nm-thick  $\text{BaSi}_2$ , 200-nm-thick  $\text{Ba}_{0.71}\text{Sr}_{0.29}\text{Si}_2$  and  $\text{Ba}_{0.48}\text{Sr}_{0.52}\text{Si}_2$ , and 100-nm-thick  $\text{Ba}_{0.36}\text{Sr}_{0.64}\text{Si}_2$  measured at RT.

Figure 4 Sr composition, x, dependence of indirect absorption edges in  $\text{Ba}_{1-x}\text{Sr}_x\text{Si}_2$  measured at RT.

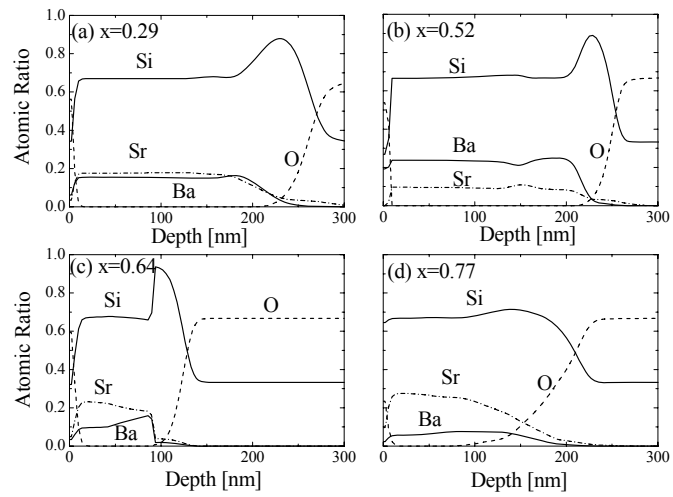


Fig. 1 Morita *et al.*

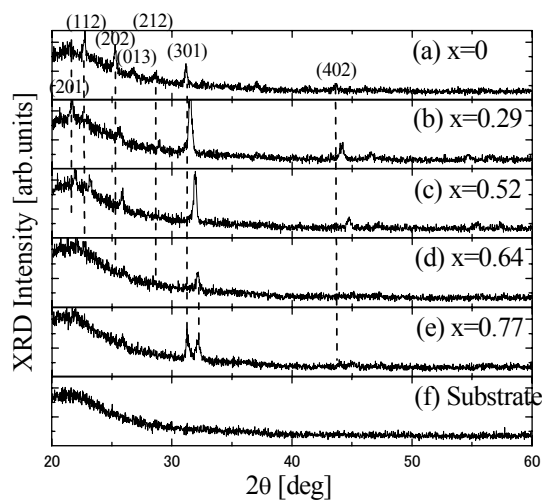


Fig. 2 Morita *et al.*

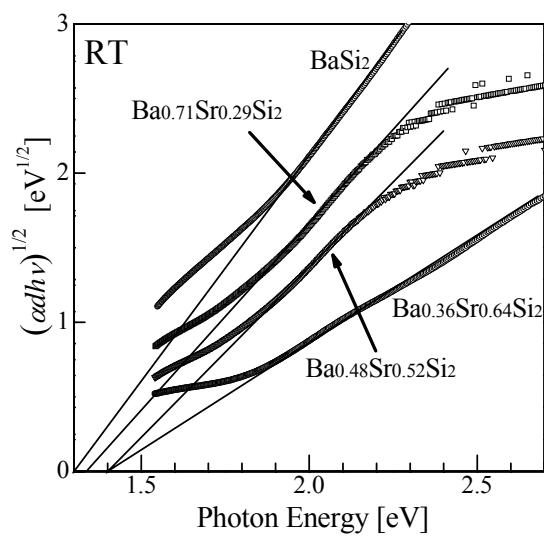


Fig. 3 Morita *et al.*

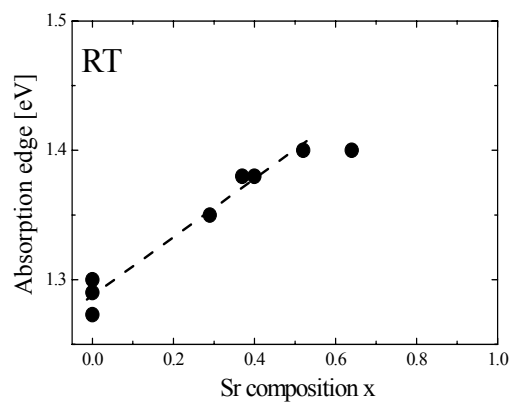


Fig. 4 Morita *et al.*